

Nicholas Fuller, graduate student at Columbia University, was awarded two major American Vacuum Society awards

1. AVS Graduate Research Award for 2001 (~ 6 such awards each year)
2. John Coburn and Harold Winters Student Award
 - from the Plasma Sciences and Technology Division of the AVS
 - "presented to the student whose paper is judged to be most outstanding based on technical content and quality of presentation"
 - one award is presented each year

The title of his talk at AVS, 2001 was "Laser Desorption-Laser Induced Fluorescence *in situ* Studies of Si Etching in Inductively-Coupled Cl₂-Ar Plasmas"

Mr. Fuller is fully supported by NSF DMR-98-15846, and will be receiving his Ph.D. in summer, 2002.



I. P. Herman, DMR 98-15946, "Optically Probing the Chemistry of Thin Film Processes"

I. P. Herman, DMR 9815946

Nicholas Fuller

the graduate student supported by my DMR 98-15946, "Optically Probing the Chemistry of Thin Film Processes" award, has just been selected to receive an AVS Graduate Research Award for 2001. I understand that the American Vacuum Society makes about 6 such awards each year.

the John Coburn and Harold Winters Student Award. This award is from the Plasmas Sciences and Technology Division of the American Vacuum Society and "is presented to the student whose paper is judged to be most outstanding based on technical content and quality of presentation." One award is presented each year.

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